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(54) Title: PARTICULATE WATER RETAINING MATERIAL FOR CULTIVATING PLANT HAVING WATER ABSORBENT RESIN AS MAIN COMPONENT

(57) Abstract: A particulate water retaining material for cultivating plant comprising (A) a carboxyl group-containing water-insoluble water absorbent resin and (B) a polyvalent metal compound, by having the compound (B) deposited on the the rerin (A), it is made possible to possess an outstanding water absorbing property without impairing the growth of a plant.